Interface Modification in Type-II ZnCdSe/Zn(Cd)Te QDs for High Efficiency Intermediate Band Solar Cells

V.Deligiannakis$^{1,3}$, S. Dhomkar$^1$, M. S. Claro$^1$, I. L. Kuskovsky$^{2,3}$, M. C. Tamargo$^{1,3}$

$^1$City College of CUNY, 160 Convent Ave., New York, New York 10031, USA
$^2$Queens College of CUNY, 65-30 Kissena Blvd, Queens, New York 11367, USA
$^3$The Graduate Center of CUNY, 365 Fifth Avenue, New York, New York 10016, USA  
vdeligia@gmail.com

Abstract: A new growth process for type-II ZnCdSe/ZnCdTe quantum dots (QDs) is developed to avoid formation of deleterious strain-inducing ZnSe interfacial layer (IL) that forms during the migration enhanced epitaxy growth process used to form the QDs. This new growth sequence allows for improved control of the interfacial composition and simplifies the fabrication of the intermediate band solar cell device structure based on these QDs, since additional strain balancing schemes are no longer required to grow stress-free structures. In contrast to previous results, lattice-matched QD superlattices were obtained using near lattice-matched ZnCdSe barrier layers. X-ray diffraction and excitation intensity dependent photoluminescence studies were used to support such a conclusion. Our findings have applications for the growth of other heterointerfaces in which an undesirable IL may form due to lack of a common anion, and to desorption and incorporation of competing elements.

Introduction:

Intermediate band solar cells (IBSCs) have been proposed$^1$ as a possible solution to overcoming the Shockley-Queisser limit$^2$ for solar cell quantum efficiencies. In these, a mid-gap energy band is formed, for instance by quantum dots within a relatively large bandgap semiconductor matrix.$^3$ Type-II ZnCdSe/ZnCdTe submonolayer QDs have been explored by our group for their promising properties as IBSCs.$^{4,5,6}$ The ZnCdSe host material when lattice matched to InP has an energy bandgap of ~2.1 eV in which the ZnCdTe QDs can form an intermediate band with an energy 0.5 – 0.7 eV. The similarity of these parameters with those required for an ideal IBSC makes this material system an outstanding candidate. In the current state of IBSCs using type-I QDs grown by the Stranski-Krastanov (SK) method have shown significant advances.$^7,8$ However, highly efficient devices have not you been realized. Due to the small size and low density of QDs, many layers are required to achieve an appreciable absorption response. The QDs grown by the SK method require the formation of a strained wetting layer, and so as the QD layers are repeated multiple times the strain increases, decreasing the overall quality of the material.$^9$ Non-radiative processes are enhanced by defects that arise from strain within a layer.$^{10}$ Furthermore, type-I band alignment systems that have been pursued are prone to exhibit Auger recombination, a non-radiative recombination process that can reduce the quantum efficiency of solar cell. This process is suppressed in type-II systems due to the separation of electrons and holes.$^{11}$ By growing sub-monolayer type-II quantum dots by migration enhanced epitaxy (MEE) which proceeds via the Volmer-Weber mechanism, one can avoid the formation of strained wetting layers thus minimizing strain effects, and also suppress Auger recombination phenomena.

However, other challenges arise during the growth of these materials due to the lack of a common anion as well as Cd desorption during the MEE growth of QDs.$^{12,4}$ Typically, an unintentional ZnSe interfacial layer (IL) is formed at the interface of the ZnCdSe spacer material and the QDs, causing high tensile strain, modifying the band structure of the resulting materials. This requires adjustments in barrier and QD cadmium concentrations to fabricate stress free devices by strain balancing.$^6$ complicating growth and increasing potential cost. The presence of the IL is also problematic due do its uncontrolled nature and its modification of the resulting band structure. Here we report the results of modified growth sequences that can suppress the formation of this IL, allowing for better control of the QD band structure and eliminating the need for strain balancing schemes to obtain high structural quality.

Growth:

A series of ZnCdSe/ZnCdTe QD superlattice (SL) samples were grown with varying source shutter sequences during the process of QD formation. A schematic of the structure is shown in Figure 1. The initial buffer layers and spacer material (ZnCdSe) were grown by molecular-beam epitaxy (MBE), whereas to achieve the formation of sub-
monolayer ZnCdTe QDs the MEE process was implemented. All samples were grown on (001) oriented InP substrates with a 100 nm lattice matched InGaAs buffer layer to ensure the formation of a high quality II-VI/III-V interface. The II-VI layer structure for all the samples includes a 100 nm ZnCdSe buffer layer, followed by a superlattice consisting of alternating 2-4 nm thick ZnCdSe spacer layers and the submonolayer ZnCdTe QDs. The formation of ZnCdTe QDs was achieved by using a shutter sequence of alternating Zn, Cd and Te fluxes with short wait times between them, with no impingent fluxes, to achieve MEE conditions.

The previously used shutter sequence developed by our group (shown in Fig. 2a) entailed a growth interruption with exposure of a Zn and Cd flux for 5s after the growth of the ZnCdSe spacer, followed by a short 5 s wait time without any shutters open. Then the Te flux was opened for 5s and followed again by a 5 s wait time without any impingent fluxes. This sequence was repeated several times (cycles). The number of cycles used were either three or four depending on the desired quantum dot size and composition. At the end of the MEE sequence the Zn and Cd shutters were opened simultaneously for 5s before resuming the ZnCdSe spacer layer growth (by opening the Se shutter). The interruptions or “wait times” are intended, to allow excess Zn and Cd to desorb, and for the Zn, Cd and Te to aggregate, and form quantum dots.

In this work, modifications of the shutter sequence (Fig 2b) using a 5s Cd-only exposure between the growth of the spacer layer and the MEE cycles and reducing the “wait time” after the Cd exposure to 1s were explored in an attempt to suppress the ZnSe tensile layer formation at the interface. Three samples (A, B and C) were grown for this comparison. Two additional samples, D and E, were also grown to obtain a lattice matched superlattice region using the unmodified growth sequence of sample A and the new optimum growth sequence of sample C. Table I summarizes some of the relevant growth parameters for the samples.

Results and Discussion:
Sample A was grown following the growth sequence of Figure 2a. Sample B was grown using the growth sequence shown in Figure 2b, with a Cd-only exposure and a 5s “wait time” after the Cd exposure, and sample C was grown using the sequence of Figure 2b but using only a 1s “wait time” after the Cd-only exposure. HR-XRD 20–ω scans were taken around the (004) and (224) reflections to characterize the structural parameters of the grown samples. Figure 3

<table>
<thead>
<tr>
<th>Sample</th>
<th>$T_{ext}$ (C)</th>
<th>Te Flux ($10^{-7}$ Torr)</th>
<th>Period</th>
<th>Cycle</th>
<th>Interface</th>
</tr>
</thead>
<tbody>
<tr>
<td>A</td>
<td>270</td>
<td>9.0</td>
<td>50</td>
<td>4</td>
<td>Zn, Cd</td>
</tr>
<tr>
<td>B</td>
<td>285</td>
<td>8.5</td>
<td>100</td>
<td>3</td>
<td>Cd</td>
</tr>
<tr>
<td>C</td>
<td>282</td>
<td>8.5</td>
<td>100</td>
<td>3</td>
<td>Cd</td>
</tr>
<tr>
<td>D</td>
<td>285</td>
<td>8.5</td>
<td>100</td>
<td>3</td>
<td>Cd</td>
</tr>
<tr>
<td>E</td>
<td>280</td>
<td>8.0</td>
<td>100</td>
<td>3</td>
<td>Zn, Cd</td>
</tr>
</tbody>
</table>

Table I Relevant growth parameters for all samples.
shows the HR-XRD spectra for sampled A, B and C. Scans along the (004) symmetric reflection show the Bragg diffraction peaks of the various layers grown on InP substrates including the InGaAs and ZnCdSe buffer layers and the zeroth (0\(^0\))-order superlattice peak (SL(0)) as well as higher order satellite peaks, which originate from the periodic ZnCdSe/ZnCdTe QD superlattice structure. Although the superlattice includes 2-4 nm ZnCdSe spacer it has been shown that as little as a single monolayer of ZnSe (~0.3nm) can result in high tensile strain in contrast to the expected small compressive strain due to the ZnCdTe submonolayer QD material. This high tensile strain is evident by the appearance of the SL(0) peak at higher than the substrate Bragg angles, indicative of tensile strain.

The stress contribution from QDs is expected to be very small due to their submonolayer nature, so that the lattice constant of the SL is dominated by the IL and the composition of the spacer layer.

To estimate the strain accurately the (224) asymmetric reflection was also measured (Figure 3b). Using both (004) and (224) reflections one can calculate both the out-of-plane, \(a_\perp\), obtained directly from the (004) reflection measurement, and the inplane, \(a_\parallel\), lattice parameters. The latter is calculated as shown in Eq. 1, where \(d_{hKL}\) is the distance between crystallographic planes.

\[
Eq. 1 \quad a_\parallel = \frac{8}{1/d_{224}^2 - 1/d_{004}^2} 
\]

Then, one can calculate the “unstrained” lattice parameter, \(a_0\), using Eq. 2, where \(C_{11}\) and \(C_{12}\) are the elastic constants \(C_{ij}\) of the layer of interest (SL(0) or ZnCdSe buffer).\(^6\)

\[
Eq. 2 \quad a_0 = \frac{a_\perp + 2C_{12}a_{sub}}{C_{11}} 
\]

Calculation of \(a_0\) for the Zn\(_{x}\)Cd\(_{1-x}\)Se buffer is straightforward, since the elastic constants can be approximated by interpolation to the ternary composition. For the SL(0) peak, the elastic constants are estimated taking into account the ZnCdSe spacer layer, as well as the thickness of the interfacial layer present.

Comparing \(a_0\) with the InP lattice constant we can see that the SL(0) peak for all the samples are nearly pseudomorphic with the InP substrate. The degree of relaxation of each of layer can be calculated by Eq.3,

\[
Eq. 3 \quad R = \frac{a_\parallel - a_{sub}}{a_0 - a_{sub}} 
\]

The results are shown in Table 2. As expected, the previously adopted growth sequence, used in sample A, did not suppress the formation of a ZnSe IL. In that sample, the higher order superlattice peaks are broad and weak, consistent with rough interfaces. The SL(0) peak for sample A shows a tensile strain of 2.00% with respect to the substrate. Using Vegard’s law and assuming a fully strained IL we calculate that approximately 2 monolayers of ZnSe from at the interface between the spacer layer and QDs.

**Figure 3** (a) HR-XRD along the (004) reflection; SL(0) mismatch is minimized with optimal growth sequence (sample C). (b) The (224) asymmetric reflection. (c) SL(-1) of the (004) reflection.
By contrast, sample B shows a large reduction of the SL(0) mismatch as a result of having a Cd-only exposure during the initial growth interruption prior to the MEE cycles. Samples B and C show successively smaller tensile strains of 0.86% and 0.47%, respectively, due to the suppression of the IL formation. The reduced strain results in a lower estimated ZnSe thickness of 1 and ~0.75 monolayers for samples B and C, respectively. We interpret this dramatic effect on the IL formation to the fact that Zn has a stronger affinity than Cd to bond with Se so it will displace Cd from ZnCdSe surface, and to the greater likelihood of Cd to desorb during the growth interruption when both the Zn and Cd shutters are open. When only the Cd shutter is open, as in sample B, the competition between Zn and Cd is diminished and the effect of Cd desorption is suppressed. In sample C, by also shortening the wait time between the ZnCdSe spacer and the start of the MEE cycle to 1 s, instead of the 5 s used in sample B, the desorption of Cd is further reduced. The satellite peaks of the superlattice SL(0) peak are narrower in samples B and C, as is shown in figure 3c, indicating smoother interfaces in those samples. From these results we conclude that the shutter sequence for sample C is optimal, since it results in the strongest suppression of the ZnSe IL.

Table II Lattice parameters and relaxation (R) for samples A, B and C.

<table>
<thead>
<tr>
<th>Sample</th>
<th>Layer</th>
<th>$a_1$</th>
<th>$a_2$</th>
<th>$a_0$</th>
<th>R%</th>
</tr>
</thead>
<tbody>
<tr>
<td>A</td>
<td>ZnCdSe</td>
<td>5.865</td>
<td>5.865</td>
<td>5.865</td>
<td>Matched</td>
</tr>
<tr>
<td></td>
<td>SL(0)</td>
<td>5.753</td>
<td>5.870</td>
<td>5.818</td>
<td>Strained</td>
</tr>
<tr>
<td>B</td>
<td>ZnCdSe</td>
<td>5.880</td>
<td>5.864</td>
<td>5.871</td>
<td>Matched</td>
</tr>
<tr>
<td></td>
<td>SL(0)</td>
<td>5.820</td>
<td>5.871</td>
<td>5.849</td>
<td>Strained</td>
</tr>
<tr>
<td>C</td>
<td>ZnCdSe</td>
<td>5.885</td>
<td>5.872</td>
<td>5.878</td>
<td>34% Relaxed</td>
</tr>
<tr>
<td></td>
<td>SL(0)</td>
<td>5.840</td>
<td>5.872</td>
<td>5.858</td>
<td>Strained</td>
</tr>
</tbody>
</table>

To verify that the new shutter does not affect the type-II band alignment and retains the favorable optical properties needed for the IBSC we measured the PL spectra for sample D. Figure 5 shows the 77 K excitation intensity dependent PL emission which was taken by using a 50 mW 405 nm diode laser and collected with a Ocean Optics 2000 spectrometer. A strong broad PL emission typical of type-II structures is seen. The ZnCdTe QD PL is centered at 1.92 eV. A small peak at 2.14 eV can be observed at high excitations, which we attribute to the ZnCdSe spacer and/or buffer layer. Furthermore, as expected for type-II heterostructures, the intensity dependent blue shift of the PL emission peak is clearly observed (Fig. 5 b). Our results
indicate that the materials grown with the modified shutter sequence, which have improved structural properties, with greatly reduced formation of the deleterious ZnSe IL retain the good optical properties typical of these type-II QD systems. Sample E, which was the Thus, we conclude that this new growth sequence is favorable for the design of an optimum IBSC.

Conclusion:

We have modified the MEE shutter sequence used in the growth of submonolayer ZnCdTe type-II QDs for use in IBSCs in order to reduce the formation of a deleterious ZnSe interfacial layer that was previously reported. We have shown that a Cd-only exposure at the start of the MEE shutter sequence, along with a reduced “wait time” after the Cd exposure greatly suppresses the ZnSe IL formation. The results are consistent with the suppression of Cd depletion from the ZnCdSe spacer region at the start of the growth interruption prior to the MEE growth sequence. We propose that two processes are responsible for the Cd depletion during the Zn and Cd exposure of the previously used growth sequence: Cd desorption due to its small sticking coefficient at the growth temperatures, and replacement of Cd by the Zn in the impinging flux, due to the stronger affinity of Zn than Cd to bond to Se. The resultant materials have improved structural properties while maintaining their good optical characteristics. The results presented here have implications in other heterostructure systems in which the lack of a common anion results in unwanted interfacial layer formation.

Figure 5 (a) Low temperature intensity dependent PL for sample D confirms the type-II band alignment between QDs and host material. (b) (c)
References:


